Attorney's Docket 040258-0280043 Exient Reference: EL00026CDC

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

re PATENT APPLICATION of:

Confirmation Number: 4153

TADAHIRO OHMI ET AL.

Application No.: 09/827,307

Group Art Unit: 1763

Filed: April 6, 2001

Examiner: L. Alehandro Mulero

Commissioner for Patents P.O. Box 1450

For:

JUN 0 3 2004

Alexandria, VA 22313-1450

### AMENDMENT/RESPONSE TRANSMITTAL

PLASMA PROCESSING APPARATUS AND PLASMA PROCESSING METHOD

Transmitted herewith is an amendment/response for this application.

### **FEES**

The fee for claims and extension of time (37 C.F.R. 1.16 and 1.17) has been calculated as shown below:

	CLAIMS REMAINING	HIGH	HEST NO.							
	AFTER PREVIOUSLY AMENDMENT PAID FOR			PRESENT EXTRA		RATE		ADDIT. FEE		
		· · · · · ·			_	×				
TOTAL	12		20	=	0	\$\$	18.00	=	\$	0.00
						X				
INDEP.	3	_	3	=	0	\$	86.00	=	\$	0.00
FIRST PRESENTATION OF MULTIPLE DEP. +										
CLAIM						\$	290.00	=	\$	0.00
TOTAL ADDITIONAL CLAIM FEE									\$	0.00
GRAND TOTAL									\$	0.00

#### **FEE PAYMENT**

Authorization is hereby made to charge the amount of \$0.00 to Deposit Account No. 033975. Charge any additional fees required by this paper or credit any overpayment in the manner authorized above. A duplicate of this paper is attached.

Date: June 3, 2004

PILLSBURY WINTHROP LLP

P.O. Box 10500 McLean, VA 22102 (703) 905-2110 DEFERENT D. KARCESK

Reg. No. 35914

1763 AF





# REPLY UNDER 37 C.F.R. § 1.116 EXPEDITED PROCEDURE TECHNOLOGY CENTER ART UNIT 1763

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Title: PLASMA PROCESSING APPARATUS AND PLASMA PROCESSING METHOD

June 3, 2004

## RESPONSE UNDER 37 C.F.R. § 1.116

Mail Stop AF Hon. Commissioner of Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Final Office Action, mailed March 17, 2004, the date for response to which is June 17, 2004, reconsideration and allowance of the present application based on the following remarks is respectfully requested.